

1. Record Nr.	UNINA9910973261003321
Titolo	Synthesis and engineering of nanostructures by energetic ions // Devesh Kumar Avasthi and Jean Claude Pivin, editors
Pubbl/distr/stampa	New York, : Nova Science Publishers, Inc., c2012
ISBN	1-62100-237-3
Edizione	[1st ed.]
Descrizione fisica	1 online resource (390 p.)
Collana	Nanotechnology science and technology Novinka
Altri autori (Persone)	AvasthiDevesh Kumar PivinJean Claude
Disciplina	620/.5
Soggetti	Nanostructured materials - Design and construction Nanostructures - Design and construction Ion bombardment - Industrial applications
Lingua di pubblicazione	Inglese
Formato	Materiale a stampa
Livello bibliografico	Monografia
Note generali	Description based upon print version of record.
Nota di bibliografia	Includes bibliographical references and index.
Nota di contenuto	Intro -- SYNTHESIS AND ENGINEERING OF NANOSTRUCTURES BY ENERGETIC IONS -- SYNTHESIS AND ENGINEERING OF NANOSTRUCTURES BY ENERGETIC IONS -- CONTENTS -- PREFACE -- A. SYNTHESIS OF NANOCOMPOSITE THIN FILM AND NANOSTRUCTURES AT SURFACE BY LOW ENERGY ION BEAMS -- ENERGETIC ION BEAMS IN NANOSTRUCTURING: AN OVERVIEW -- 1. INTRODUCTION: -- 2. ION OF ENERGIES UPTO A FEW MEV IN SYNTHESIS OF NANOSTRUCTURES -- 2.1. Synthesis of Nanocomposite Thin Films by Atom Beam Co-Sputtering -- 2.2. Creation of Nanoripples at Surface by KeV Ion Beams -- 2.3. Buried Nanostructures by Ion Implantation -- 2.4. Buried Nanostructures by Ion Beam Mixing -- 2.5. Precipitation Resulting from Electronic Energy Deposited by Ions -- 3. HIGH ENERGY (SWIFT HEAVY IONS) IN SYNTHESIS OF THE NANOSTRUCTURES -- 3.1. Creation of Carbon Nanowire in Si Based Gels -- 3.2. Creation of Carbon Nanowires in Fullerene -- 3.3. Si and Ge Nanoparticles by SHI Irradiation of Si and Ge Suboxide -- 3.4. Reduction of Copper Oxide Nanoparticles by SHI -- 3.5. Latent Tracks as Templates for Nanostructures -- 3.6. Ion Tracks in Polymers for Grafting Functional Monomers -- 4. HIGH ENERGY (SWIFT HEAVY IONS) IN MODIFYING THE NANOSTRUCTURES --

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Sommario/riassunto

Materials with nanometric dimensions such as nanodots, nanowire, nanotubes, functional structures, multi-layers of low dimensions, have unique properties, which can be tuned by varying their size. This book reviews research on applications and theoretical modelling of ion beams in the field of nanotechnology.
